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Patterned $L1_0$ -FePt for polarization of magnetic films

Yannick Dusch,^{a)} Nicolas Tiercelin, Alexey Klimov,^{b)} Vasyi Rudenko, Yury Ignatov,^{b)} Sami Hage-Ali, Philippe Pernod, and Vladimir Preobrazhensky^{c)}

International Associated Laboratory LEMAC: IEMN, UMR CNRS 8520, PRES Lille Nord de France, ECLille, 59651 Villeneuve d'Ascq, France

In various micro and nanosystems applications comprising magnetic films, the polarizing field still needs to be integrated. We hereby present a solution for the self biasing of magnetic films using micropatterned permanent magnets. Micromagnetic simulations were used as a designing and optimization tool to create a biasing structure. The samples were fabricated with varying geometric parameters using classical silicon microfabrication techniques. Nanostructured TbCo/FeCo magnetostrictive thin films were sputtered over coercive FePt filled trenches etched in silicon. Magnetic and magneto-elastic characterizations confirmed the numerical simulations. In particular, nonlinear actuation of a self-biased magnetostrictive cantilever has been obtained at a zero external polarizing field.

I. INTRODUCTION

The polarization of free magnetic layers in micro- and nano-electro-mechanical-systems (MEMS and NEMS) can be obtained by several means depending upon the requirements of the application. Macroscopic magnets can be used in research or industrial environments but prevent any size reduction of the systems. Spintronic devices or NEMS can benefit from thin exchange coupled layers. Nevertheless, due to the short length of the interactions, such nanostructures are hard to implement for thick active layers in the 100 nm- 1 μ m range. The use of permanent magnet-induced boundary fields has also been investigated using SmCo¹ or CoPt² and was proven to be efficient for biasing magnetoresistive layers up to 200 nm and several hundred oersteds. In any case, the typical length of the system along the biasing direction did not exceed a few hundred microns.

We hereby propose the use of micropatterned $L1_0$ -FePt sputtered films to polarize magnetic thin films with larger in-plane dimensions. In this study, we used such structures to induce a spin reorientation transition (SRT) in giant magnetostrictive nanostructured thin films for applications in MEMS and NEMS. Indeed, it was shown that nanostructured giant magnetostrictive films under field induced SRT can be made highly sensitive to magnetic excitations and exhibit strong nonlinear behavior.³ This feature of the SRT conditions opens the route toward, for example, original magneto- electric microsensors, microactuators, or RF devices.⁴ In particular, the magnetoelectric effect is dramatically enhanced near the SRT in composite magnetostrictive/piezo- electric layered structures.⁵ Such a critical state can only be obtained when the bias field H_{Bias} directed along the hard

axis of magnetization (HA) reaches the anisotropy field H_a of the layer.

II. NUMERICAL SIMULATIONS

As shown in Fig. 1, the structure consists of parallel FePt trenches etched in a silicon substrate on top of which a Ta spacer and a [TbCo(5 nm)/FeCo(5 nm)]*n multilayer are deposited. The multilayer exhibits uniaxial magnetic anisotropy. The easy axis of magnetization (EA) is obtained in the multilayer thanks to sputtering under a magnetic field. Magnetostatic simulations of the flux density show that alternate polarized areas are created in the active layer due to the coupled or isolated flux closure (Fig. 2). This leads to a striped magnetic structure in the active layer (parts 1 and 2, as shown in Fig. 1). The shape of the global hysteresis curve of the active layer along the HA can be evaluated by super- posing the two shifted curves of the stripes, as illustrated in Fig. 3(a). Both parts exhibit a Stoner-Wohlfarth like rotation of magnetization.

Using the open source micromagnetic simulation software Magpar,⁶ we investigated the effects of several biasing structures on a magnetic thin film with in-plane uniaxial anisotropy. It appears that the structure presented above offers a good trade-off between the obtained polarization along the HA and technological simplicity. Figure 3(b) presents a typical result of the numerical simulations, clearly showing the striped pattern of magnetization on top of the active layer.

FIG. 1. Schematic view of the biasing structure.

^{a)}Author to whom correspondence should be addressed. Electronic mail: yannick.dusch@centraliens-lille.org.

^{b)}International Associated Laboratory LEMAC: V. A. Kotelnikov Institute of Radioengineering and Electronics, 125009 Moscow, Russia.

^{c)}International Associated Laboratory LEMAC: Wave Research Center, GPI RAS, 38 Vavilov str., Moscow, 119991, Russia.

FIG. 2. Simulated flux lines [FEMM (Ref. 7). Irregularities in the flux lines are due to simulation artifacts]. Arrows indicate the main direction of magnetization.

Magpar has then been used to carry out numerous simulations with varying geometric parameters (FePt/silicon width ratio, trench width, FePt thickness, Ta gap thickness) to optimize the strength and the homogeneity of the bias field.

III. EXPERIMENT

Filled trenches of hard magnetic material have already been realized with SmCo and NdFeB, but the process involved a critical phase of chemical-mechanical-planarization.⁸ We present here a simpler process for FePt, based on lift-off.

Prototypes were realized on Si wafers by the usual microfabrication techniques in a cleanroom environment. Silicon is first etched through an aluminum mask by means of deep reactive ion etching (DRIE) down to 2 μm . A 100 nm Ta adhesive layer as well as a thick (2 μm) FePt layer are then deposited by RF sputtering. Lift-off is used to remove the excess material. FePt is obtained by the RF sputtering of a composite target under an Ar flow at 5×10^{-3} mbar. Sputtering is decomposed into 15 min runs followed by a rest period of 4 min to prevent the detrimental effects of temperature, such as internal stress. A 100 nm Ta nonmagnetic spacer (also used to prevent oxidation of FePt during annealing) is added on top of the structure before annealing at 750°C during 30 min under a secondary vacuum (1×10^{-6} mbar) to obtain the $L1_0$ phase of FePt. This process led to a coercive field of $H_c = 1$ T. The nanostructured active layer is deposited by RF sputtering under a homogeneous magnetic field (obtained by permanent magnets placed on the substrate holder). Alternating the sputtering of TbCo and FeCo composite targets led to 25 exchange-coupled 10 nm bilayers (250

FIG. 4. SEM view of the processed microstructure. FePt is finally polarized along HA. A typical result of this process is shown on Fig. 4. The vertical structure at the interface between FePt and Si is due to DRIE combined with masking effects.

Two sets of samples have been fabricated: 25 samples with centimeter dimensions on a 3 in wafer with different geometric parameters ($L = 20$; 50; 100; 200; and 400 μm and $L_{\text{FePt}} = L = 0.7$; 0.6; 0.5; 0.4; and 0.3) and 5 samples fabricated on a thin (150 μm) 2 in silicon wafer to obtain centimeter-sized cantilevers for magnetoelastic characterizations.

IV. RESULTS AND DISCUSSION

A. Magnetic characterizations

First measurements were made using a vibrating sample magnetometer (VSM) (ADE EV9 Series) with sub- μm resolution. Figure 5 presents VSM measurements of the magnetization of a sample with the following characteristics: $L = 50$ μm , $L_{\text{FePt}} = 25$ μm , FePt thickness $e_{\text{FePt}} = 2$ μm , Ta spacer thickness $e_{\text{spacer}} = 100$ nm, active layer thickness $e = 250$ nm. The contribution of FePt has been removed beforehand on the curve. As shown in Fig. 5, the global hysteresis curve $M(H_{\text{ext}})$ of the biased active layer along the HA is composed of two shifted contributions (compared to the unbiased reference), each accounting for half of the magnetic stripes. Both shifts are almost symmetrical with a bias field of approximately 500 Oe. Since in some cases slope changes are difficult to observe, we also used the derivatives of the hysteresis curves which are also presented in Fig. 5.

Longitudinal magneto-optic Kerr effect (LMOKE) measurements have been carried out to investigate the magnetic microstructure on the surface of the nanostructured active layer and validate the interpretation of the VSM measurements. Due to the size limitations of the experimental setup measurements could not be carried out on every

FIG. 3. (a) Schematic illustration of the hysteresis curve of the active layer when the polarizing field is superior to the anisotropy field (b) Top view of the simulated active layer with $H_{\text{ext}} = 0$ Oe, $L_{\text{FePt}} = 25$ μm and $L = 50$ μm . Arrows indicate magnetization.

FIG. 5. Hysteresis curve (a) and derivative of the hysteresis curve (b) of the active layer (Solid: biased, dashed: unbiased).

sample. Nevertheless, the results obtained for $L = 100 \mu\text{m}$ and $L_{\text{FePt}} = 50 \mu\text{m}$ confirmed our interpretations. The hysteresis curves for each part of the magnetic structure can be seen in Fig. 6. As expected, when the FePt is magnetized, two adjacent stripes (namely part 1 and part 2) show opposite offsets along the HA. Here, the offsets are, respectively, 100 Oe and 200 Oe.

B. Magneto-elastic characterizations

Magneto-elastic characterizations have been carried out by a laser deflection technique on a centimeter sized silicon cantilever on top of which the biasing structure has been realized. The cantilever is placed inside the core of a driving coil producing a dynamic magnetic field along the EA of the active layer. The cantilever is then placed under a homogeneous static magnetic field created by an electromagnet along the HA. The flexural or torsional vibration amplitude of the free tip is measured by the deflection of a laser beam on a 2D position sensing diode. As predicted by theory,⁹ due to giant nonlinearity near the SRT, subharmonic magnetic excitation at $f_r/2$ with f_r a resonant frequency of the cantilever, results in an amplified mechanical vibration at f_r near the SRT point ($H_{\text{Bias}} \approx H_a$). Figure 7 shows the results for a $2 \text{ cm} \times 0.5 \text{ cm} \times 150 \mu\text{m}$ cantilever for the second flexural mode at $f_r = 3124 \text{ Hz}$.

As expected, nonlinear actuation of the system occurs for shifted values of the external magnetic field, compared to an unbiased sample and even exists without any external field, as the bias field is close to the anisotropy field $H_a = 300 \text{ Oe}$.

FIG. 6. MOKE measurements of a biased sample ($L = 100 \mu\text{m}$, $L_{\text{FePt}} = 50 \mu\text{m}$) (Solid line: biased, dashed line: unbiased).

FIG. 7. Magnetoelastic measurement (Solid line: biased, dashed line: unbiased).

V. CONCLUSIONS

In this paper, we have proposed an integrated permanent magnet based microstructure for the polarization of magnetic thin films. Micromagnetic simulations proved efficient as a sizing and optimization tool for such structures. Several samples have been successfully fabricated due to a MEMS-compatible process. In the case of a giant magnetostrictive thin film, integrated VSM along with local LMOKE magnetic characterizations confirmed the numerical studies. Moreover, magnetoelastic measurements showed that because of the integrated polarization, subharmonic actuation of a cantilever could be obtained without any external static field. These results pave the way for the development and the integration of innovative and multifunctional micro-magneto-mechanical- and micro-magneto-electro-mechanical-systems.

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